

# PRINTER RUSH

(PTO ASSISTANCE)

Application : <u>10532550</u>	Examiner : <u>Falano</u>	GAU : <u>1794</u>
From: <u>J. Blach</u>	Location: <u>IDC</u> FMF FDC	Date: <u>7/1/08</u>
Tracking #: <u>epmla532550</u>		Week Date: <u>6/23/08</u>

DOC CODE	DOC DATE	MISCELLANEOUS
<input type="checkbox"/> 1449		<input type="checkbox"/> Continuing Data
<input checked="" type="checkbox"/> IDS	<u>8/1/05</u>	<input type="checkbox"/> Foreign Priority
<input type="checkbox"/> CLM		<input type="checkbox"/> Document Legibility
<input type="checkbox"/> IIFW/FWCLM		<input type="checkbox"/> Fees
<input type="checkbox"/> SRFW		<input type="checkbox"/> Other
<input type="checkbox"/> DRW		
<input type="checkbox"/> OATH		
<input type="checkbox"/> 312		
<input type="checkbox"/> SPEC		

[RUSH] MESSAGE:

Please initial line through citations (last page).

Thank you!

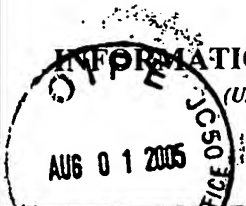
[XRUSH] RESPONSE:

OK  
lost my attach

INITIALS: zh

EXAMINER: PUBS contacts -- for DESIGNS: Don Fairchild, 703-308-9250 x126; for ALL OTHER FILES:  
Bernadette Queen, 703-308-9250 x121

NOTE: This form will be included as part of the official USPTO record, with the Response document  
coded as XRUSH.

 <p><b>INFORMATION DISCLOSURE CITATION</b> (Use several sheets if necessary)</p>	Docket number (Optional) <b>16169.6</b>	Application Number <b>10/532,550</b>
	Applicant(s) <b>Ishii, et al.</b>	
	Filing Date <b>4/22/2005</b>	Group Art Unit <b>Not Yet Assigned</b>

* Examiner Initial	OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)
/LF/	U.S. Patent Application No. 10/532,564 entitled "GLASS SUBSTRATE FOR INFORMATION RECORDING MEDIUM AND METHOD FOR MANUFACTURING SAME," filed April 22, 2005.
/LF/	U.S. Patent Application No. 10/532,538 entitled "GLASS SUBSTRATE FOR INFORMATION RECORDING MEDIUM AND METHOD FOR MANUFACTURING SAME," filed April 22, 2005.

EXAMINER <b>/Louis Falasco/</b>	DATE CONSIDERED <b>2/2/2007</b>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.